

Electronic Acknowledgement Receipt

EFS ID:	1379630
Application Number:	10734749
International Application Number:	
Confirmation Number:	9525
Title of Invention:	Method for producing a hard mask in a capacitor device and a hard mask for use in a capacitor device
First Named Inventor/Applicant Name:	Haoren Zhuang
Customer Number:	20985
Filer:	Scott C. Harris/Sharon Gebhart
Filer Authorized By:	Scott C. Harris
Attorney Docket Number:	14580-045001 / FP2078
Receipt Date:	15-DEC-2006
Filing Date:	11-DEC-2003
Time Stamp:	19:48:52
Application Type:	Utility

Payment information:

Submitted with Payment	no
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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1		lfa38000.PDF	327172	yes	11

Multipart Description/PDF files in .zip description		
Document Description	Start	End
Amendment - After Non-Final Rejection	1	1
Claims	2	4
Applicant Arguments/Remarks Made in an Amendment	5	11

Warnings:	
Information:	
Total Files Size (in bytes):	327172

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If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371
If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.